

ERNST-MORITZ-ARNDT UNIVERSITY OF
GREIFSWALD

MASTER THESIS

Kinetic effects in RF discharges

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“Without encroaching upon grounds appertaining to the theologian and the philosopher, the domain of natural sciences is surely broad enough to satisfy the wildest ambition of its devotees. [...] The work may be hard, and the discipline severe; but the interest never fails, and great is the privilege of achievement. ”

— John William Strutt, 3rd Baron Rayleigh, 1884
in: Address to the British Association in Montreal

Declaration of Authorship

I hereby certify that this thesis has been composed by me and is based on my own work, unless stated otherwise. No other person's work has been used without due acknowledgement in this thesis. All references and verbatim extracts have been quoted, and iall sources of information, including graphs and data sets, have been specifically acknowledged.

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Signature of author
Greifswald; July 14, 2017

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Abstract

The Thesis Abstract is written here and usually kept to just this page. The page is kept centered vertically so it can expand into the blank space above the title too.

Physical properties of low temperature RF plasma

In this first chapter I will provide the necessary physical background for this work about the numerical simulation of low temperature capacitively coupled radio frequency plasma. Here both the mathematical basics and method for the simulation, as well as the most important aspects about the plasma properties will be explained.

1.1 Basic plasma physics

1.1.1 Capacitively coupled radio frequency plasma

1.1.2 Sheath physics and wall interaction

1.1.3 Self bias voltage

1.1.4 Dielectric displacement current

1.2 Negative ion physics

1.2.1 Anion creation and distribution

1.2.2 Dynamics and collisions

1.3 Particle-In-Cell simulations with Monte Carlo-Collisions

1.3.1 Principles

1.3.2 2d3v PIC

1.3.3 Monte Carlo-Collisions

Validation of Simulation by 1d comparison

2.1 Axial density profiles

2.2 Velocity and energy distributions

2.3 Transition to 2d simulation

Simulation of capacitively coupled rf discharges

- 3.1 Experimental setup
- 3.2 Secondary ion emission
- 3.3 Anion energy distributions in oxygen

Epilogue

- 4.1 Local electrostatic field solver
- 4.2 Diagnostics of current and charge
- 4.3 Field calculation
- 4.4 Comparison with Poisson-based solvers

Conclusion